

L Number	Hits	Search Text	DB	Time stamp
1	0	((silicon near3 nitride) Si3N4 ("Si.sub3" adj "N.sub.5")) near50 (wet clean\$3 treat\$3) near50 ((carbon near5 water) (((CO2 "CO.sub.2") (carbon near3 dioxide)) near5 (water H2O ("H.sub.2" adj "O")))))	USPAT; US-PGPUB	2003/08/08 09:22
2	12	((silicon near3 nitride) Si3N4 ("Si.sub3" adj "N.sub.5")) same (wet clean\$3 treat\$3) same ((carbon near5 water) (((CO2 "CO.sub.2") (carbon near3 dioxide)) near5 (water H2O ("H.sub.2" adj "O")))))	USPAT; US-PGPUB	2003/08/08 09:25
3	3	((silicon near3 nitride) Si3N4 ("Si.sub3" adj "N.sub.5")) same (wet clean\$3 treat\$3) same ((carbon near5 water) (((CO2 "CO.sub.2") (carbon near3 dioxide)) near5 (water H2O ("H.sub.2" adj "O")))))	EPO; JPO; DERWENT; IBM_TDB	2003/08/08 09:25